



JPW B/A

AMENDMENT AFTER ALLOWANCE  
EXPEDITED PROSECUTION - GROUP ART UNIT 2828

03500.013974.1

PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:

TADAHIRO OHMI ET AL.

Application No.: 09/985,707

Filed: November 6, 2001

For: LASER GAS SUPPLY PATH  
STRUCTURE IN AN EXPOSURE  
APPARATUS

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Examiner: Davienne N. Monbleau

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Group Art Unit: 2828

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May 18, 2004

Mail Stop: Issue Fee  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

DO NOT ENTER  
DM 9-15-04

AMENDMENT UNDER 37 C.F.R. § 1.312

Sir:

a) Introductory Comments

This application having been allowed, please amend the claims as follows: